## Notice of References Cited Application/Control No. | Applicant(s)/Patent Under | Reexamination | FUKIAGE, NORIAKI | Examiner | Art Unit | Page 1 of 1

## **U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	Α	US-4,960,488 A	10-1990	Law et al.	438/694
*	В	US-5,788,799 A	08-1998	Steger et al.	156/345.37
*	С	US-5,952,060 A	09-1999	Ravi, Kramadhati	427/577
*	D	US-2002/0029748 A1	03-2002	Kuwada et al.	118/724
*	E	US-6,410,102 B1	06-2002	Hashizume et al.	427/534
*	F	US-2003/0097987 A1	05-2003	Fukuda, Hideaki	118/723.00E
	G	US-			
	Н	US-			
	ı	US-		2	
	J	US-			
	К	US-			
	L	US-			
	М	US-			

## FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
*	N	EP 0 387 656 A1	03-1990	EUROPE (EU)	TSUKUNE, ET AL.	C23C 16/44
	0					
	Ρ					
	Q					
	R					
	S		,			
	Т					

## **NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	υ	Mahorowala, A.P., Babich, K., Petrillo, K., Simons, J., Angelopoulos, M., Patel, V., and Grill, A. "Tunable Anti-Reflective Coatings with Built-in Hard Mask Properties Facilitating Thin Resist Processing," Proceedings of SPIE (4343): 306 – 316, 2001
	V	
	V	
	×	

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)

Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.